Electron-Hole Asymmetric Chiral Breakdown of Reentrant Quantum Hall States

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Reentrant integer quantum Hall (RIQH) states are believed to be correlated electron solid phases, although their microscopic description remains unclear. As bias current increases, longitudinal and Hall resistivities measured for these states exhibit multiple sharp breakdown transitions, a signature unique to RIQH states. A comparison of RIQH breakdown characteristics at multiple voltage probes indicates that these signatures can be ascribed to a phase boundary between broken-down and unbroken regions, spreading chirally from source and drain contacts as a function of bias current and passing voltage probes one by one. The chiral sense of the spreading is not set by the chirality of the edge state itself, instead depending on electron- or holelike character of the RIQH state.

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A variety of exotic electronic states emerges in high mobility 2D electron gases (2DEGs) at very low temperature and in a large out-of-plane magnetic field. The most robust are the integer quantum Hall states, described by discrete and highly degenerate Landau levels. When the uppermost Landau level is partially filled, electrons in that level may reassemble into a fractional quantum Hall (FQH) liquid [1–3] or condense into charge-ordered states, from Wigner crystals to nematic stripe phases [4–13]. Such charge-ordered states, or electron solids, are observed primarily above filling factor $\nu = 2$, where Coulomb effects are strong in comparison to magnetic energy scales. They are believed to be collective in nature [14], prone to thermodynamic phase transitions like melting or freezing of a liquid.

Numerical simulations of electron solids indicate alternating regions of neighboring integer filling factors with dimensions on the order of the magnetic length [15,16]. When the last Landau level is less than half filled, the electron solid takes the form of “bubbles” of higher electron density in a sea of lower density (an electronlike phase). Above half filling, the bubbles are of lower electron density, giving a holelike phase. Insulating bubble phases lead to “reentrant” transitions of the Hall resistivity up or down to the nearest integer quantum Hall plateau, giving rise to the reentrant integer quantum Hall (RIQH) effect.

The microscopic description and thermodynamics of RIQH states remain topics of great interest [12,14–17]. Most experimental input into these questions has come from monitoring RIQH state collapse at elevated temperature or high current bias [14,17–21]. The temperature-induced transition out of insulating RIQH states is far more abrupt than would be expected for activation of a gapped quantum Hall liquid, consistent with their collective nature. RIQH collapse at elevated temperature is apparently a melting transition of the electronic system out of the electron solid state [14].

Elevated current biases induce transitions out of the insulating RIQH state that occur via sharp resistance steps, a phenomenon that has been interpreted in terms of sliding dynamics of depinned charge density waves [22] or alignment of electron liquid crystal domains by the induced Hall electric field [17]. These interpretations assume that bias-induced phase transitions happen homogeneously across the sample. On the other hand, finite currents through a quantum Hall sample generate highly localized Joule heating. Considering the collective nature of RIQH states, this suggests a mechanism for forming inhomogeneous phases across a macroscopic sample.

Here, we show that resistance signatures of high current breakdown for RIQH states reflect a macroscopic phase separation induced by the bias. That is, the breakdown process itself is sharply inhomogeneous, with the electronic system after breakdown spatially fractured into regions that are either melted (conducting) or frozen (insulating). For all RIQH states from $\nu = 2$ to $\nu = 8$, the breakdown propagates clockwise or counterclockwise from the source and drain contacts with a sense that depends on the electron- or holelike character of the particular RIQH state. The data are explained by a phase boundary between frozen and melted regions that spreads around the chip following the location of dissipation hot spots.
Measurements were performed on a 300 Å symmetrically doped GaAs/AlGaAs quantum well with low temperature electron density $n_e = 3.1 \times 10^{11}$ cm$^{-2}$ and mobility $15 \times 10^5$ cm$^2$/V s [23]. Electrical contact to the 2DEG was achieved by diffusing indium beads into the corners and sides of the 5 × 5 mm chip [Fig. 1(a)]. FQH characteristics were optimized following Ref. [24]. Differential resistances $R \equiv dV/dI_b$ for various contact pairs were measured at 13 mK by lock-in amplifier with an ac current bias $I_{ac} = 5$ nA at 71 Hz. A dc current bias $I_{dc}$ was added to the ac current in many cases. At zero dc bias, characteristic $R_{xx}$ and $R_{xy}$ traces over $2 < \nu < 3$ show fragile FQH states as well as four RIQH states, labeled $R2a–R2d$ [Fig. 1(c)] (refer to the Supplemental Material for a complete labeling of reentrant states [25]). At high current bias, the RIQH states disappear, with $R_{xy}$ moving close to the classical Hall resistance, while most fractional states remain well resolved.

The RIQH breakdown process can be visualized in 2D resistance maps versus $I_{dc}$ and magnetic field. Figure 1 presents several such maps for the holelike $R2c$ state ($\nu = 5/2$), where the Hall resistance reenters to the integer value $R_{xy} = \hbar/3e^2$. Breakdown transitions for $R_{xx}$ [Fig. 1(b)] divide the map into three distinct subregions (A, B, C), similar to observations by others [17,21]. Region A is characterized by very low $R_{xx}$: here, the electron solid state is presumably pinned and completely insulating. The sharp transition to region $B$ corresponds to a sudden rise in $R_{xx}$, while for higher bias (region $C$), the differential resistance drops again to a very small value.

The sharp transitions visible in the RIQH state breakdown [Fig. 1(b)] are absent from the neighboring $\nu = 5/2$ state. Considering the range of filling factors investigated here (see the Supplemental Material [25]) and data from many cooldowns, this behavior was observed consistently in RIQH states, but never in fractional states, pointing to distinct thermodynamic properties for the two ground states. Qualitative signatures at each pair of voltage probes ($R_{xx}$, $R_{xy}$, or the diagonal measurements $R_{yx}$ or $R_{yx}$ [Fig. 1(a)]) did not depend on the specific contacts used in the measurement but only on the arrangement of the contacts with respect to source or drain current leads (see the Supplemental Material [25]).

The observation of sharp delineations in the resistance of a macroscopic sample, measured between voltage probes separated by 5 mm, might seem to imply that the entire sample must suddenly change its electronic state for certain values of bias current and field. Then, one would expect simultaneous jumps in resistance monitored at any pair of voltage probes, albeit by differing amounts. Comparing the three pairs of voltage probes in Figs. 1(b),1(d), and 1(e), one sees immediately that this is not the case. $R_{xy}^D$ exhibits transitions at precisely the same parameter pairs $\{B, I_{dc}\}$ as $R_{xx}$, but for $R_{xy}$ no resistance change is observed at the dashed line corresponding to the $R_{xx}$ $A-B$ transition. It is well known that $R_{xy}^D$ and $R_{xy}$ can be different when the sample is inhomogeneous [26,27]. However, the extremely high quality 2DEG samples measured here are intrinsically homogeneous, as evidenced by the visibility of closely spaced and fragile fractional states.

$R_{xy}^D$ and $R_{xy}$ contacts are distinguished by the chirality of quantum Hall edge states: moving from source or drain contacts following the edge state chirality, one first comes to the $R_{xy}^D$ contacts, then to $R_{xy}$ contacts in the middle of the sample, and finally to the $R_{xy}$ contacts. The bias where the $A-B$ transition occurs for $R_{xy}$, $R_{xy}$, and $R_{xy}$ simply follows the spatial distribution of the respective voltage contacts, as shown in Fig. 2(a). An analogous breakdown behavior

![Figure 1](image1.png)

FIG. 1. (a) Measurement schematic combining ac (wiggly arrow) and dc (solid arrow) current bias through contacts 1 and 5. $R_{xx} = dV_{60}/dI_b$, $R_{xy}^D = dV_{26}/dI_b$, and $R_{xy} = dV_{84}/dI_b$. Curved arrows indicate edge state chirality. (b) Evolution of $R_{xx}$ with dc bias for the $R_{2c}$ reentrant and $\nu = 5/2$ FQH state, showing breakdown regions A, B, and C. (c) $R_{xx}$ and $R_{xy}$ ($dV_{37}/dI_b$) for filling factors $\nu = 2–3$, showing the breakdown at high dc bias. (d,e) Simultaneous measurements of (d) $R_{xy}$ and (e) $R_{xy}$, taken together with data in (b). Dashed lines are guides to the eye, denoting identical $\{B, I_{dc}\}$ parameters in (b), (d), and (e).
For a sample in the reentrant IQH regime, with $\rho_{xx} \to 0$ as before, hot spots again appear at any location where current flows from a region of higher to lower $R_{xy}$. But now, the local value of $R_{xy}$ is strongly temperature dependent, with a sharp melting transition in both longitudinal and transverse resistances [14]. The electronlike $R_{2a}$ reentrant state, for example, has $R_{xy}^{\text{reentrant}} = h/2e^2$ in the low temperature, low bias limit [Fig. 1(c)], but at higher temperature or bias, the state melts to $R_{xy}^{\text{melted}} = h/2.35e^2$. In general, electronlike states have $R_{xy}^{\text{melted}} < R_{xy}^{\text{reentrant}}$, whereas holelike states have $R_{xy}^{\text{melted}} > R_{xy}^{\text{reentrant}}$.

At low current bias in the RIQH regime, the entire sample is effectively at integer $\nu$, and only the two IQH hot spots are observed, at source and drain contacts. As the bias increases, the regions around the two IQH hot spots melt and an extra two RIQH hot spots appear where current passes into or out of the melted regions. This framework, with the $5 \times 5$ mm sample broken into macroscopic frozen and melted regions due to dissipation in local hot spots at the boundary, can explain why the breakdown phenomenology was observed only for RIQH states. A crucial ingredient in this picture is that current flowing from source to drain passes through a well-defined phase boundary, with a large and discrete jump in $R_{xx}$, even when there are continuous thermal gradients across the sample. This results from sharp electronic phase transitions, which are expected for correlated RIQH states and yield sharp jumps in $R_{xx}$ and $R_{xy}$ with elevated temperature, in contrast to activated behavior of IQH states.

Classical simulations of dissipation in a sample broken into regions with differing $R_{xy}$ (in this case, $R_{xy}^{\text{reentrant}}$ and $R_{xy}^{\text{melted}}$) confirm the connection between hot-spot location, edge chirality, and changes in filling factor. Hot spots appear where current passes from melted into frozen regions for the holelike case in Fig. 3 because $R_{xy}^{\text{melted}} > R_{xy}^{\text{reentrant}}$; they appear on the opposite sides of the melted regions for electronlike states where $R_{xy}^{\text{melted}} < R_{xy}^{\text{reentrant}}$.

Driving a current $I_b$ through a sample in the integer quantum Hall (IQH) regime, where $\rho_{xx}$ is close to 0 but $R_{xy}$ is large, requires a potential difference $R_{xy}I_b$ between source and drain. This potential drops entirely at the source and drain contacts (no voltage drop can occur within the sample since $\rho_{xx} \to 0$). Specifically, the voltage drops where the current carried along a few-channel edge state is dumped into the metallic source or drain contact—a region of effectively infinite filling factor.

FIG. 2. (a) Simultaneous measurements showing the evolution of $R_{D+}^D$, $R_{xy}$, and $R_{D-}$, with dc bias, in the middle of the $R_{2a}$ reentrant state ($I_{ac} = 5$ nA); note that this measurement uses a contact configuration rotated by 90° from Fig. 1. Evolution of (b) $R_{D+}$, (c) $R_{xy}$, and (d) $R_{D-}$ for the $R_{7a}$ reentrant state with dc bias.

(breakdown bias for $R_{D+}$ lower than for $R_{xy}$, lower than for $R_{D-}$) was consistently observed for every holelike RIQH state. For all electronlike states, a similar breakdown progression was observed but the order was opposite: breakdown bias for $R_{D+}$ higher than for $R_{xy}$, higher than for $R_{D-}$.

FIG. 3. Classical simulation of dissipation (color scale and 3D projection in a.u.) due to current flow in a sample with regions of different $R_{xy}$. Hatched semicircles are melted states near each contact with $R_{xy} = h/(2.5e^2)$; the bulk (dark blue) is the (frozen) reentrant state with $R_{xy} = h/(3e^2)$. The simulation captures hot-spot locations but does not accurately capture relative magnitudes of dissipation in different hot spots.
occurs at each titional IQH hot spots), but a second smaller potential drop sharply when passing the dc source and drain (the conventional RIQH hot spots) when the melted region is presumed to have melted-frozen boundaries for an electronlike state at intermediate bias, with associated RIQH hot spots measured [see, e.g., Figs. 4(c) and 4(d)]. This behavior can be simply explained by the hot-spot-movement mechanism outlined above, without resorting to induced anisotropy in the electron solid. Figure 4(a) and 4(b) schematics include dashed lines to show hypothetical melted-frozen boundaries for an electronlike state at intermediate bias for the (ac) orientation, compared to the conventional (ac||dc) orientation. While Ref. [17] focused on R4 states exclusively, we found analogous behavior for all reentrant states measured [see, e.g., Figs. 4(c) and 4(d)].

In conclusion, we demonstrated that bias-induced breakdown of the RIQH effect is inhomogeneous across mm-scale samples and propagates chirally from source and drain contacts with a sense that depends on the electron- or holelike character of the reentrant state. This phenomenon appears to result from a thermal runaway effect due to phase segregation and dissipation hot spots; it was observed only in (correlated) RIQH states, not fractional or integer states, pointing to their qualitatively distinct thermodynamic properties. This experiment shows the danger in interpreting macroscopic measurements at a microscopic level, especially where electronic phase transitions are sharp. On the other hand, it demonstrates the power of using breakdown characteristics as a probe into thermal properties of correlated electron states. Looking ahead, it would be particularly interesting to investigate combined Corbino and Hall bar geometries, where hot-spot-induced breakdown could be included or avoided as desired. Adding multiple small contacts within the interior of a sample would enable melted and frozen phases to be measured separately and the nature of the transition region to be probed directly.
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[25] See Supplemental Material at http://link.aps.org/supplemental/10.1103/PhysRevLett.117.166805 for further data, extending what is shown in the main text figures to other reentrant states and other sample measurement configurations. Simulation details are also included.